

L Number	Hits	Search Text	DB	Time stamp
6	640	(electron near3 beam) and (selective\$4 near3 scan\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 08:24
7	81	((electron near3 beam) and (selective\$4 near3 scan\$5)) and (secondary near3 electron)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 08:23
8	1377	(electron near3 beam) and (selective\$4 near3 irradiat\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 08:24
9	0	((electron near3 beam) and (selective\$4 near3 irradiat\$5)) and (secondary near3 electron)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 08:25
10	87	((electron near3 beam) and (selective\$4 near3 irradiat\$5)) and (secondary near3 electron)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 08:34
11	6	("3919553" "4791294" "5302828" "5977542" "6066849" "6172363").PN.	USPAT	2004/07/24 08:31
12	4	((electron near3 beam) and (selective\$4 near3 irradiat\$5)) and (secondary near3 electron) and dosage	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 09:05
13	0	sem and (dielectric near3 breakdoen)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 09:05
14	263	sem and (dielectric near3 breakdown)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 09:05
15	22	sem and (dielectric near3 breakdown) and (select\$6 near3 (irradiat\$4 deposit\$7))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 09:49
16	0	"5811819" and blank	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 09:49
17	0	"5811819" and blank\$5	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 10:01
18	0	(electron near3 beam) and (e near3 separator) and (transverse near3 aberration)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 10:02

19	2	(electron near3 beam) and (separator) and (transverse near3 aberration)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 10:46
20	516	(electron near3 beam) and (work\$5 distance) and (bore near3 diameter)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 10:07
21	57	((electron near3 beam) and (work\$5 distance) and (bore near3 diameter)) and (objective near3 lens)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 10:07
22	33	(electron near3 beam) and (work\$5 near4 distance) and (bore near3 diameter)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 10:19
23	10	(electron near3 beam) and (objective near3 lens) and (axisymmetric near4 electrode)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 10:20
24	875	separator and (objective near3 lens)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 10:47
25	110	separator and (objective near3 lens) and (electron near3 beam)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 11:52
26	11	(objective near3 lens) and (electrode) and (insulat\$5 near5 (metal\$4 near3 coating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:06
27	178	(electron near3 beam) and (electrode) and (insulat\$5 near5 (metal\$4 near3 coating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:07
28	7	(electron near3 beam) and (electrode) and (insulat\$5 near5 (metal\$4 near3 coating)) and (objective near2 lens)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:49
29	50	(therm\$5 near3 cathode) and (control\$5 near3 (heat\$4 near3 power))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:03
30	6	(therm\$5 near3 cathode) and (control\$5 near3 (heat\$4 near3 power)) and (electron near2 gun)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:26
31	10	(electrostatic near3 lens) and (electrode) and (insulat\$5 near5 (metal\$4 near3 coating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:07

32	2	(therm\$5 near3 cathode) and (control\$5 near3 (heat\$4 near3 power)) and (noise near3 signal)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:32
33	2	(electron near3 gun) and (control\$5 near3 (heat\$4 near3 power)) and (noise near3 signal)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:33
34	85	(electron near3 gun) and (control\$5 near3 (heat\$4 near3 power))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:33
35	6	3786268.URPN.	USPAT	2004/07/24 12:40
36	9	(electron near3 beam) and (electrode) and (insulat\$5 near5 (metal\$4 near3 coating)) and (electrostatic near3 lens)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/24 12:49